INSTRUCTION FOR DOCUMENT VERIFICATION AND INTERVIEW FOR EMPANELMENT OF IT RESOURCE PERSONS AGAINST Adv. No. 07/176/2019/NDL/FM)

a. Candidates who have applied for Empanelment of ***Sr. Consultant/ Project Manager, Sr. Programmer-I, System Analyst-I and Assistant Programmer 'B'*** will report to NIELIT Delhi as per schedule on following address:

> NIELIT Delhi
> 2nd Floor, Parsvnath Metro Mall
> Inderlok Metro Station
> Inderlok, Delhi-110052

b. Schedule for Interview and document verification for above mentioned post is available on NIELIT Delhi website at http://nielit.gov.in/delhi/. ***All candidates must appear for document verification and Interview in given date and time only. Those reaching late shall not be entertained.***

c. ***Only those candidates, who clear document verification, will stay for Interview. Others may leave the venue.*** Interview and document verification will be held on the same day.

d. ***Candidates must bring ALL original mark sheets, degrees, testimonials, DOB certificates, caste certificate (if applicable), experience certificate and self ATTESTED photocopies of each document along*** with **Aadhaar card** (any Govt. approved photo id) and one passport size photo on the day of document verification.

e. The shortlisted candidates will be empanelled for deployment on projects in various Govt. Depts. by NIELIT Delhi Centre on contract basis initially for the period of six months (which may be further extended based on requirements/performance of the candidate) or upto the contract period with the client. **NIELIT does not guarantee to deploy all shortlisted candidates from panel.**

f. Validity of empanelment will be three years w.e.f the date of declaration of result.

g. No TA/DA will be provided to candidates for appearing in Interview/document verification.

h. The applicants are advised to visit the website of NIELIT Delhi centre http://nielit.gov.in/delhi for **schedule, venue or any updates**. Schedule for Interview and document verification for other posts will be informed very soon.